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Highly dispersed Buckybowls as model carbocatalysts for C-H bond activation

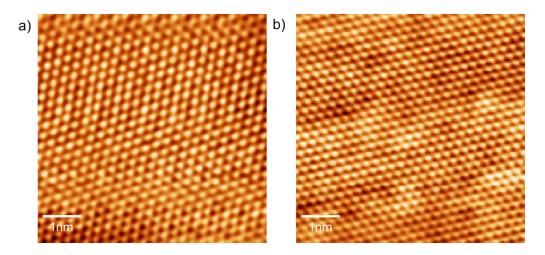
I. Ilgaz Soykal, Hui Wang, Jewook Park, An-Ping Li, Chengdu Liang* and Viviane Schwartz*,

Center for Nanophase Materials Sciences; Oak Ridge National Laboratory, Oak Ridge, TN 37831. Schwartz V.: Tel: 01-865-576-6749, E-mail: schwartzv@ornl.gov; Liang C.D.: Tel: 01-865-576-1080, E-mail: liangen@ornl.gov

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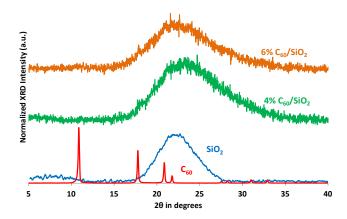
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Supplementary Information



Supplementary Figure S1. STM imaging of the pure HOPG surface before a) and after b) oxidation treatment.

To verify cleanliness of the *ex situ* oxidation procedure, we carried out the same oxidation process to the bare HOPG substrate. Figure S1a and b (6×6 nm², $V_t = 0.6$ V (A) and 0.8 V (B), $I_t = 400$ pA) show atomically resolved STM topography images of HOPG substrate both before and after oxidation process, respectively. Oxidation pretreatment had no effect on the HOPG substrate.



Supplementary Figure S2. X-ray diffraction patterns for pure C₆₀, SiO₂, 4% C₆₀/SiO₂ and 6% C₆₀/SiO₂

Supplementary Figure S2. shows the XRD patterns for pure fullerene, silica, as well as the synthesized catalysts. Pure fullerene shows strong peaks at 10.9°, 17.8°, 20.9° and 21.8° which correspond to (111), (220), (311) and (222) planes, respectively according to the reference ICDD 04-007-2472. Mesoporous silica only shows the broad 15-30° band typical for amorphous SiO₂.